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(21)Application number: 03-349681	(71)Applicant:	NIPPON SHOKUBAI CO LTD
(22)Date of filing: 06.12.1991	(72)Inventor:	HORI KOHEI
		OGINO YOSHINORI YOKOTA YOSHIYUKI
(54) PRODUCTION OF COATING RESIN		
(57)Abstract:		
PURPUSE: To provide a coating resin having excellent stabili short period.	ity and capable of forming a coating film havin	g excellent waterresistance, coating film hardness, adhesiveness and processability by baking for a
CONSTITUTION: The objective coating resin having a numl	ber-average molecular weight of 3,000-50,00	00 is produced by copolymerizing (a) 1-25wt.% of a polymerizable monomer containing acidic
iunctional group provided that 0.1-10wt.% is a polymerizable	monomer containing phosphoric acid group,	(b) 0-20wt.% of a polymerizable monomer containing hydroxyl group and (c) 55-99wt.% of
other polymerizable monomer in the presence of an aromatic	epoxy resin.	
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